



U.S. DEPARTMENT OF
ENERGY

Office of
Science

N doping: progress in development and understanding

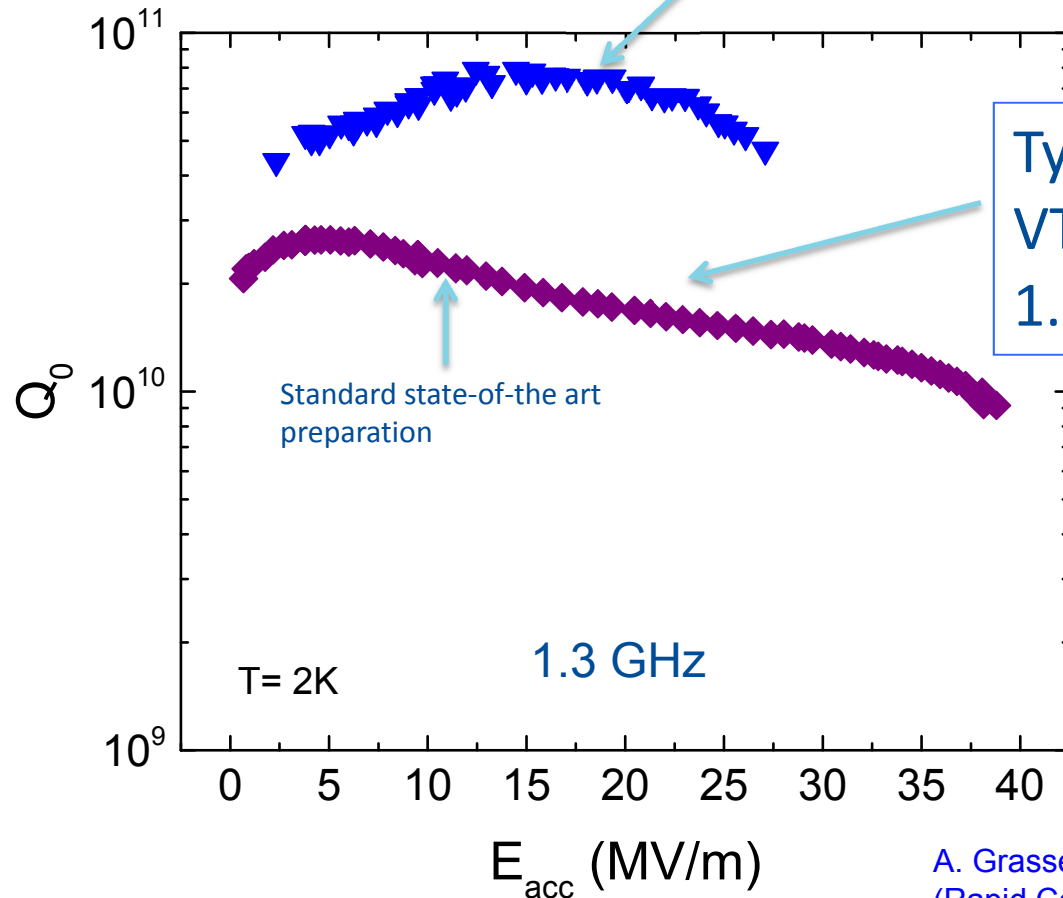
Anna Grassellino

Cavity Test and Performance Group Leader, SRF Development Department, TD

SRF conference, September 2015, Whistler, BC

Nitrogen Doping: a breakthrough in Q

Record after nitrogen doping – up to 4 times higher Q! Average values obtained on nine cell Q(2K, 16MV/m)~ 3.5e10



Typical Q obtained in VTS with 120C bake ~ 1.7e10 at 2K, 16 MV/m

A. Grassellino et al, 2013 Supercond. Sci. Technol. **26** 102001 (Rapid Communication)

A bit of history about N doping

2012

Discovery at FNAL of unprecedented Q values on single cells treated with nitrogen in high temperature furnace



2013

Developed understanding of root of Q improvement and made process controllable and reproducible

Discovered that 'light doping' improves quench fields while maintaining the benefit of high Q



2014

LCLS-2 invests in this technology, three partner labs working together FNAL-Cornell-Jlab

More than 100 N doped cavity tests with 18 nine cell qualified for the two LCLS-2 prototype cryomodules



2015

Cavity vendors currently being qualified for N doping production process for LCLS-2

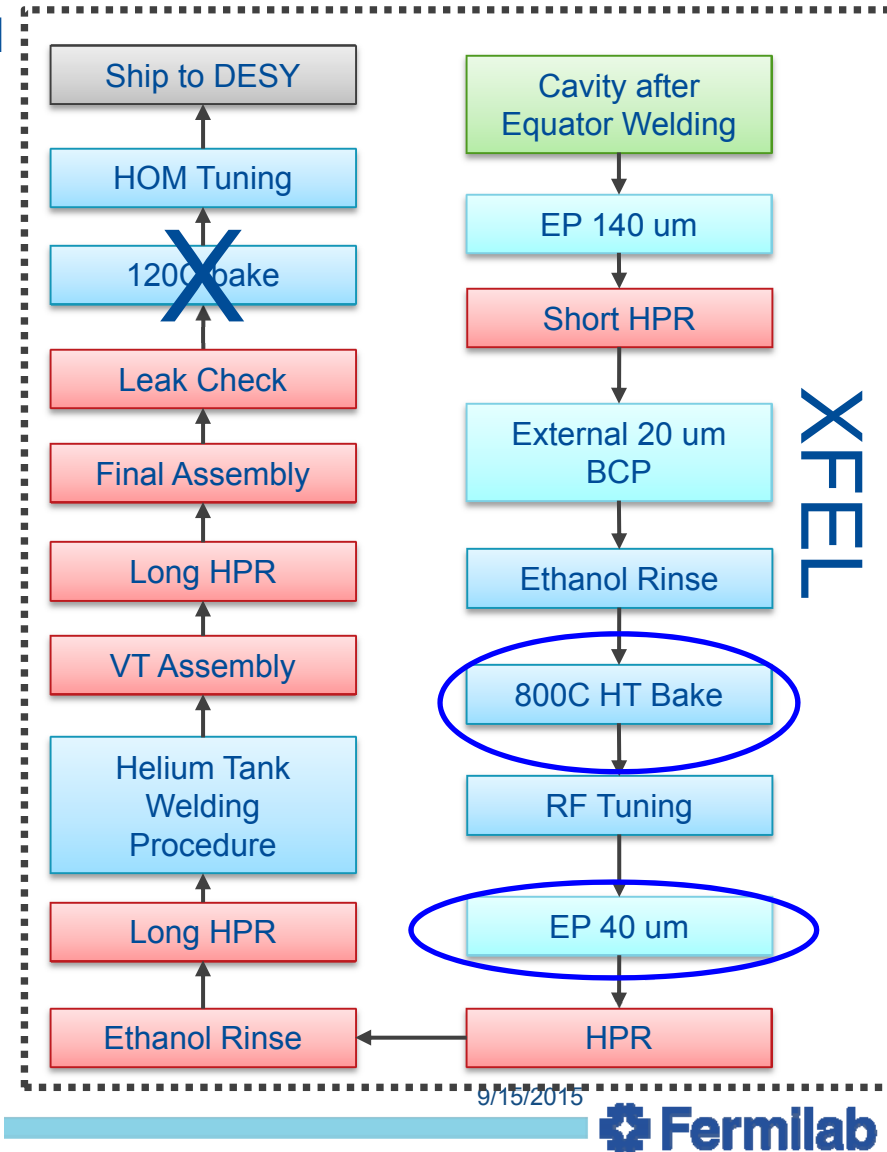
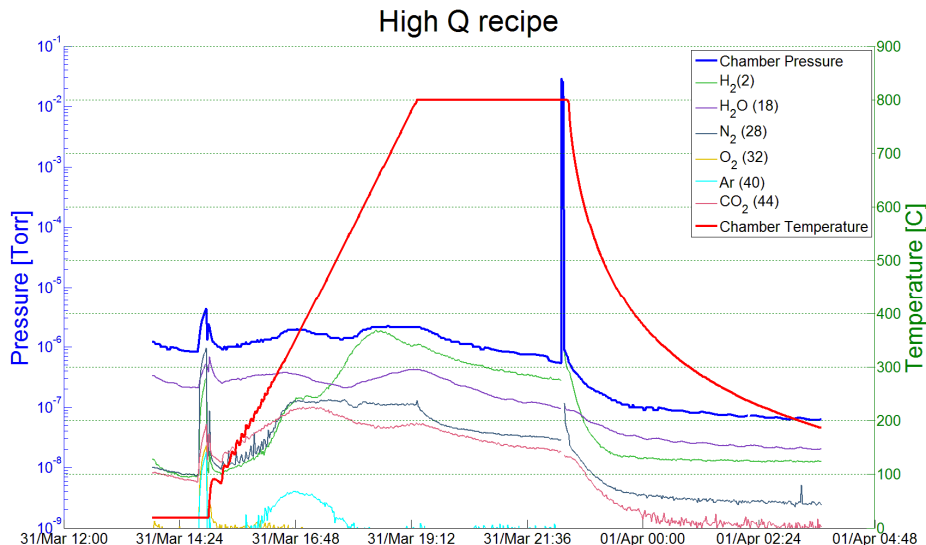
R&D continues for further understanding and improvements (quench, B sensitivity)

***Progress in N doping development:
LCLS-2 and PIP-2***

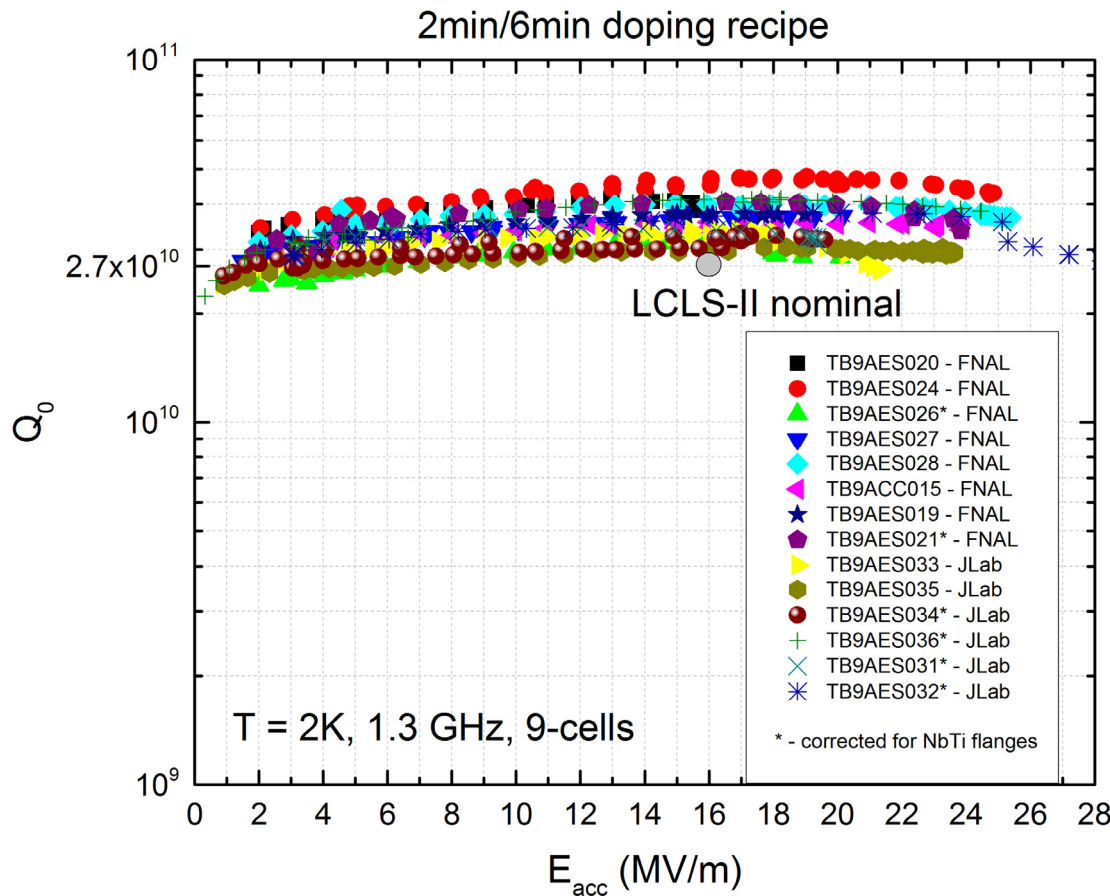
Doping Treatment: small variation from standard protocol, large difference in performance

Example from a doping process developed for LCLS-2:

- Bulk EP
- 800 C anneal for 3 hours in vacuum
- 2 minutes @ 800C nitrogen diffusion
- 800 C for 6 minutes in vacuum
- Vacuum cooling
- 5 microns EP



From single cell R&D to cryomodule ready technology: FNAL, Jlab, Cornell, SLAC together towards record $Q > 2.7 \times 10^{10}$ @16MV/m, 2K



$$\langle Q \rangle = 3.5 \times 10^{10}$$

$$\langle E_{max} \rangle = 22.2 \text{ MV/m}$$

$$E_{max} \text{ median} = 22.8 \text{ MV/m}$$

A.Grassellino et al, IPAC15

See at this conference:

MOPB033

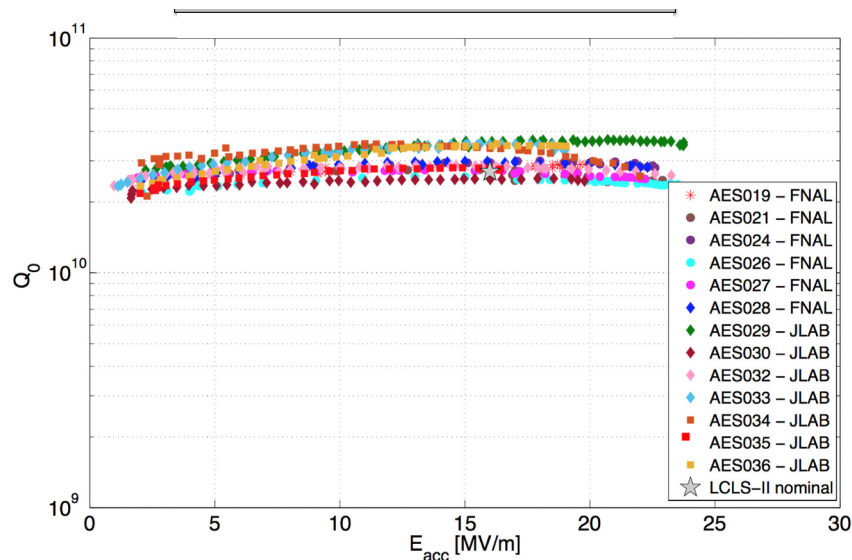
MOPB029

MOBA07

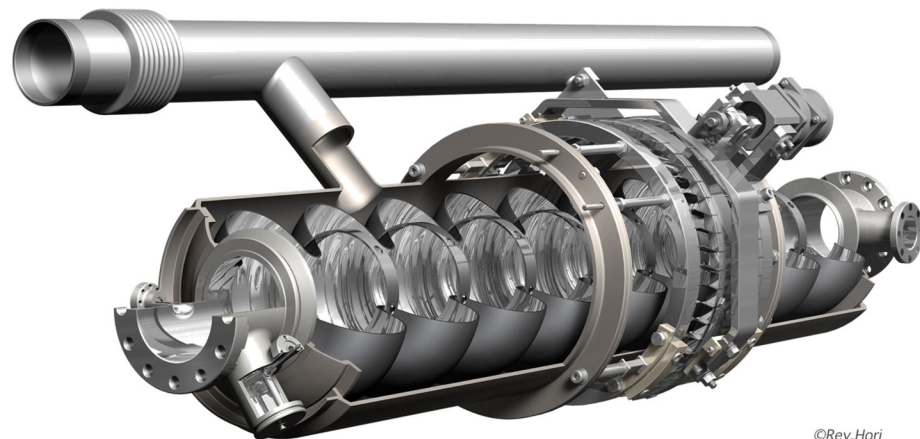
MOBA08

It is the highest average Q ever demonstrated in vertical test for
1.3 GHz nine cells at 2K, 16 MV/m in the history of SRF
(larger than a factor of two the state of the art)

N doped nine cell cavities performance post He vessel dressing



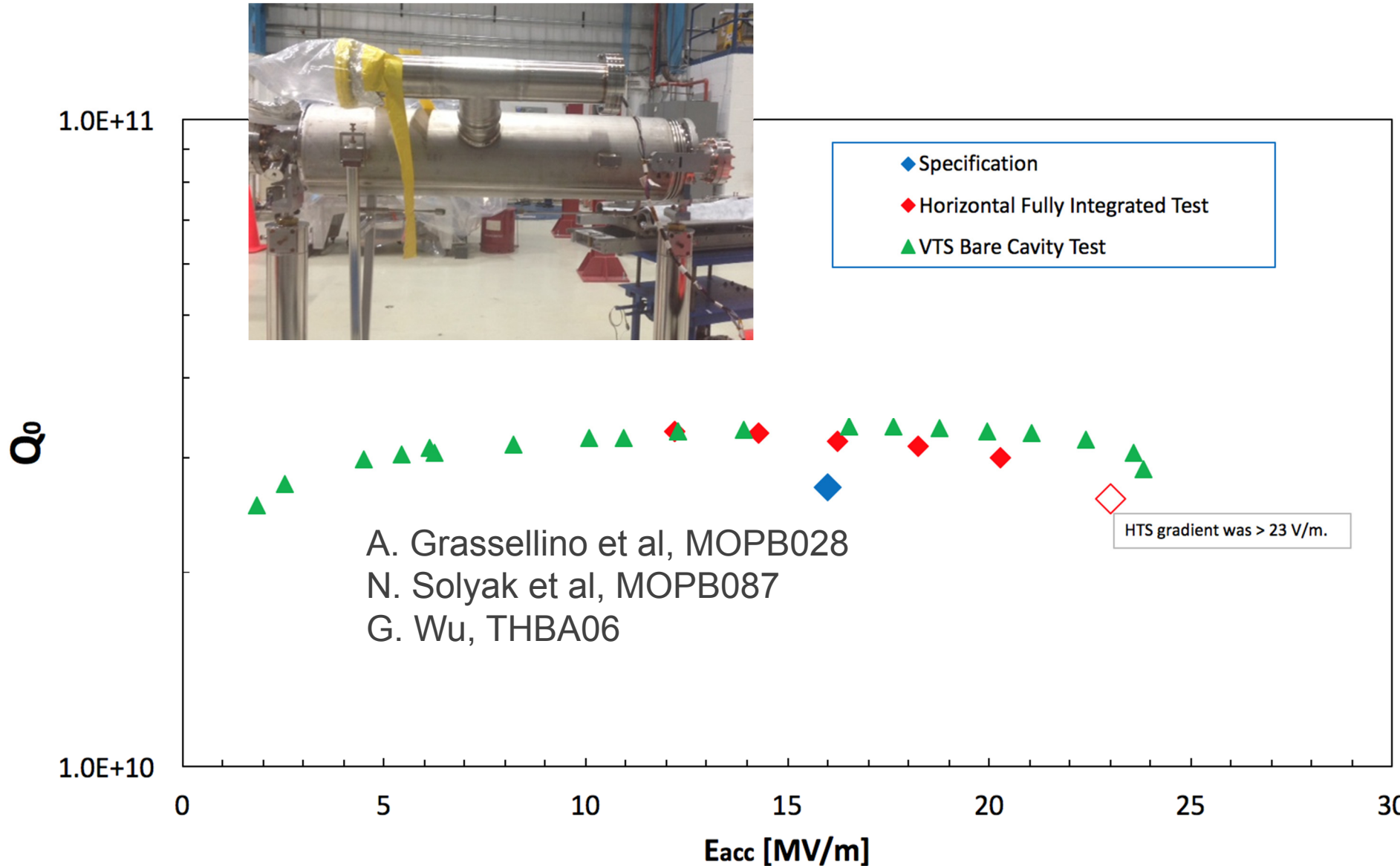
MOPB033 MOPB040
MOPB028 MOPB041



- 16 cavities dressed @ FNAL in LCLS-2 vessels ready for the prototype cryomodules – string assembly has begun, cryomodule results expected for mid 2016
- Avg VT performance still exceed $>3e10$ at 16 MV/m, 2K post dressing
- Four N doped nine cells horizontally tested in one cavity cryomodule (HTS) exceeding LCLS-2 specifications (for fast cooldowns from 45K)
- Fully integrated test : high power coupler, HOMs, tuner, magnetic shielding, thermal straps exceeding $3e10$ @ 16MV/m, 2K – proof of principle that very high Q via N doping can be preserved all the way into cryomodule

Milestone: record horizontal fully integrated test @ FNAL

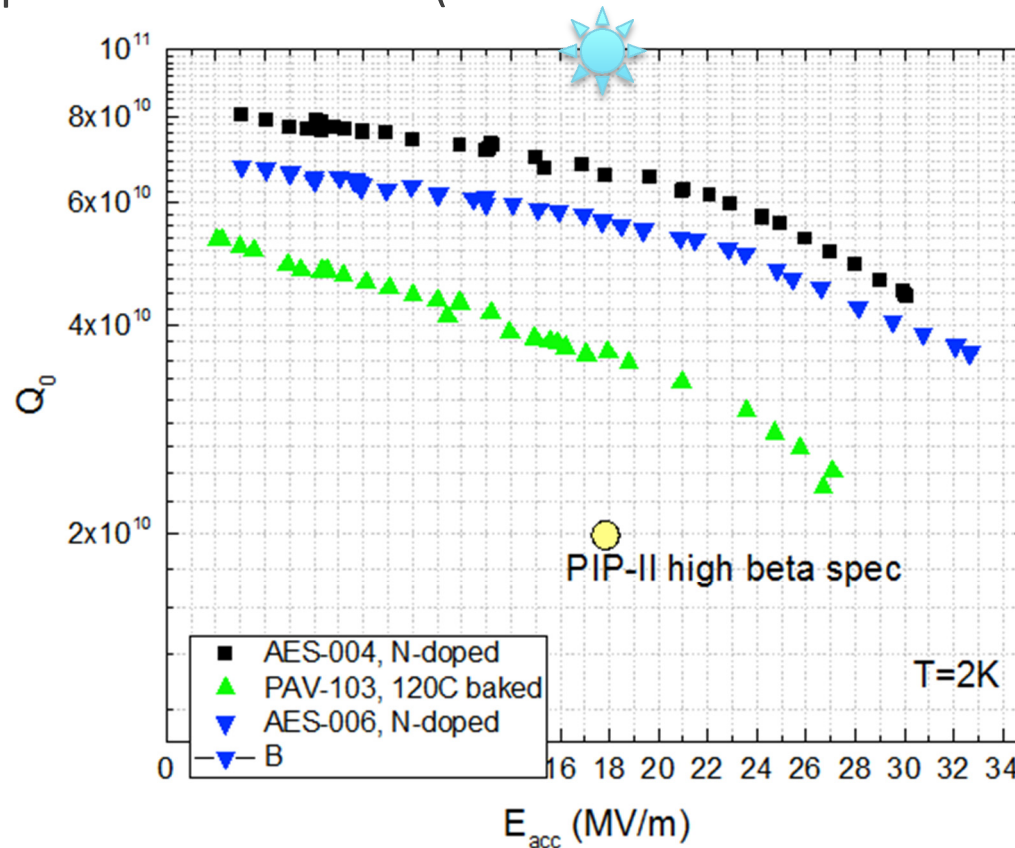
N doped nine cell in LCLS-2 vessel $>3e10$ at 16MV/m, 2K



N doping applied to 650 MHz cavities at FNAL

$Q \sim 7 \times 10^{10}$ at 2K, 17 MV/m – record values also at this frequency!

Applying N doping to 650 MHz ($\beta=0.9$) leads to double Q compared to 120C bake (standard surface treatment ILC/XFEL)



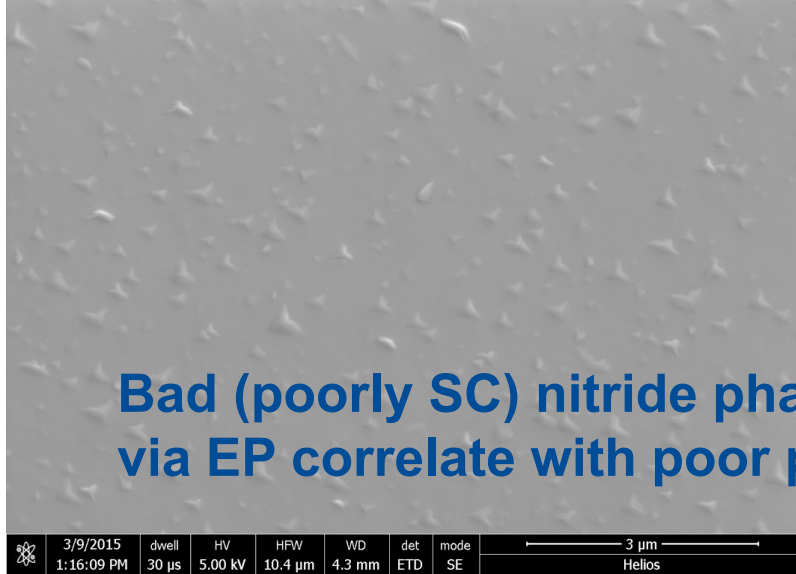
A.Grassellino,
IPAC15

But from frequency scaling from 1.3GHz, with ideal recipe the projected Q value is $\sim 1 \times 10^{11}$ at 17 MV/m, 2K! Need to optimize doping recipe at lower freq

***Progress in N doping understanding:
what is the root of performance improvement?***

Surface post N bake, pre-EP: poorly SC nitrides phases

Flat Nb sample baked at 800C°
for **2 min with N₂** + 6 min annealing



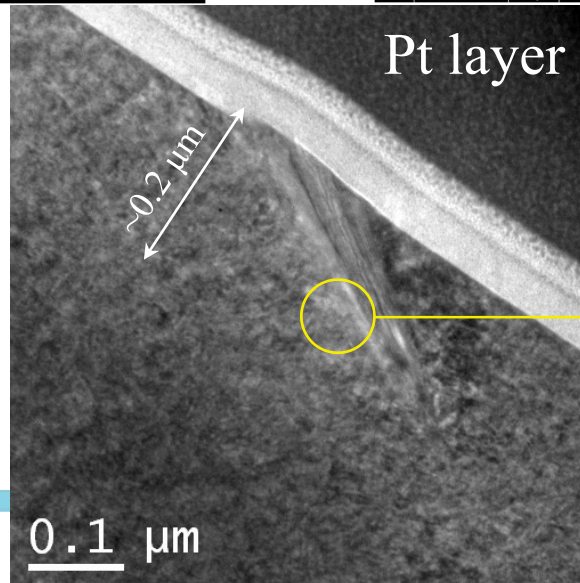
Bad (poorly SC) nitride phases that need to be removed via EP correlate with poor performance (pre-EP)

Flat Nb sample baked at 800C° for
20 min with N₂ + 30 min annealing

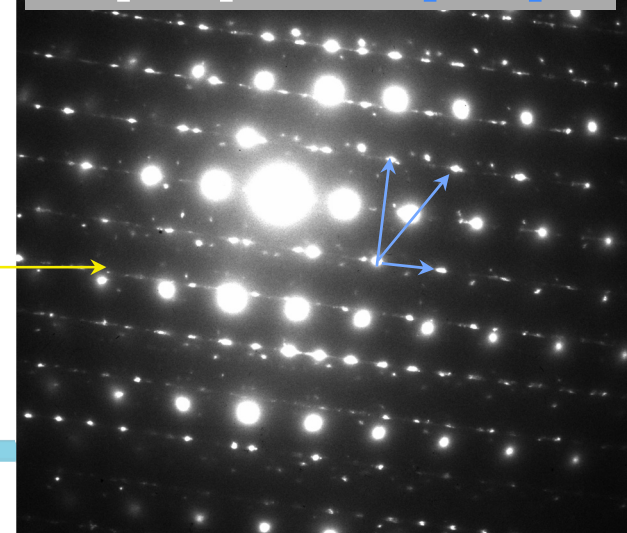


Few Nb nitrides-features (Nb₂N reflections) in Nb near-surface. Nitride “teeth” go ~0.2 μm deep

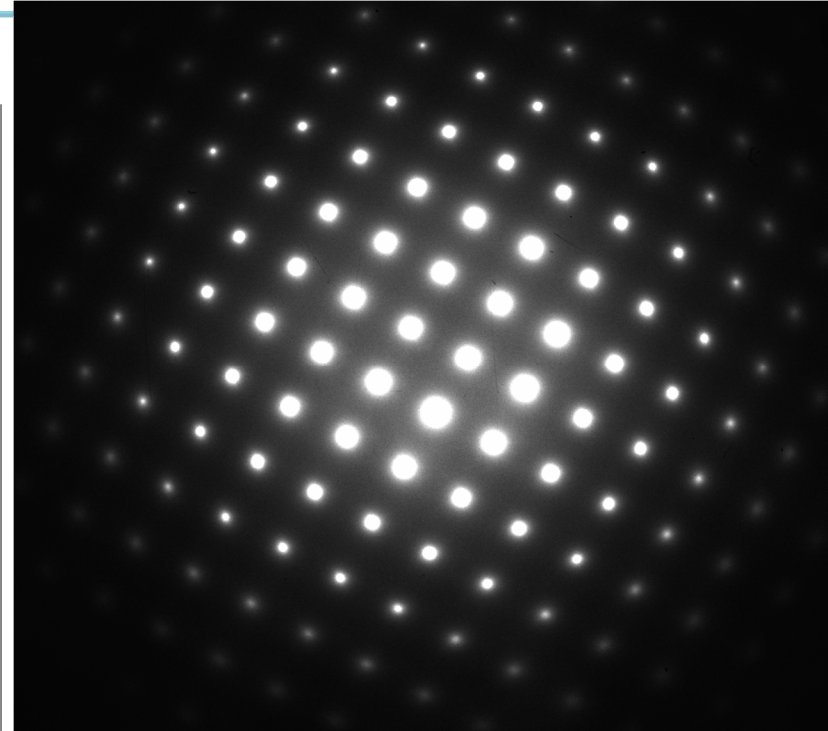
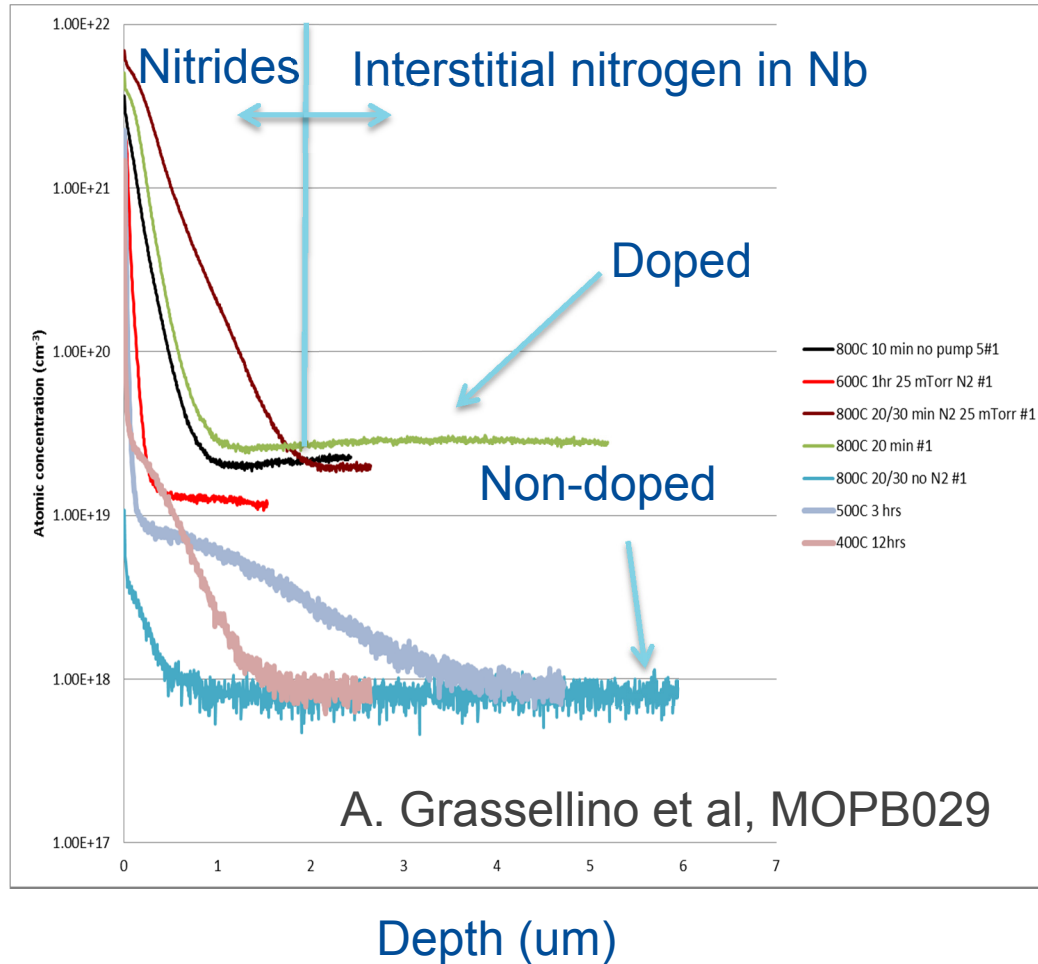
Y. Trenikhina, MOPB055



Nb [113]+Nb₂N [210]+?



Surface post N bake + EP: only low level of interstitial N left

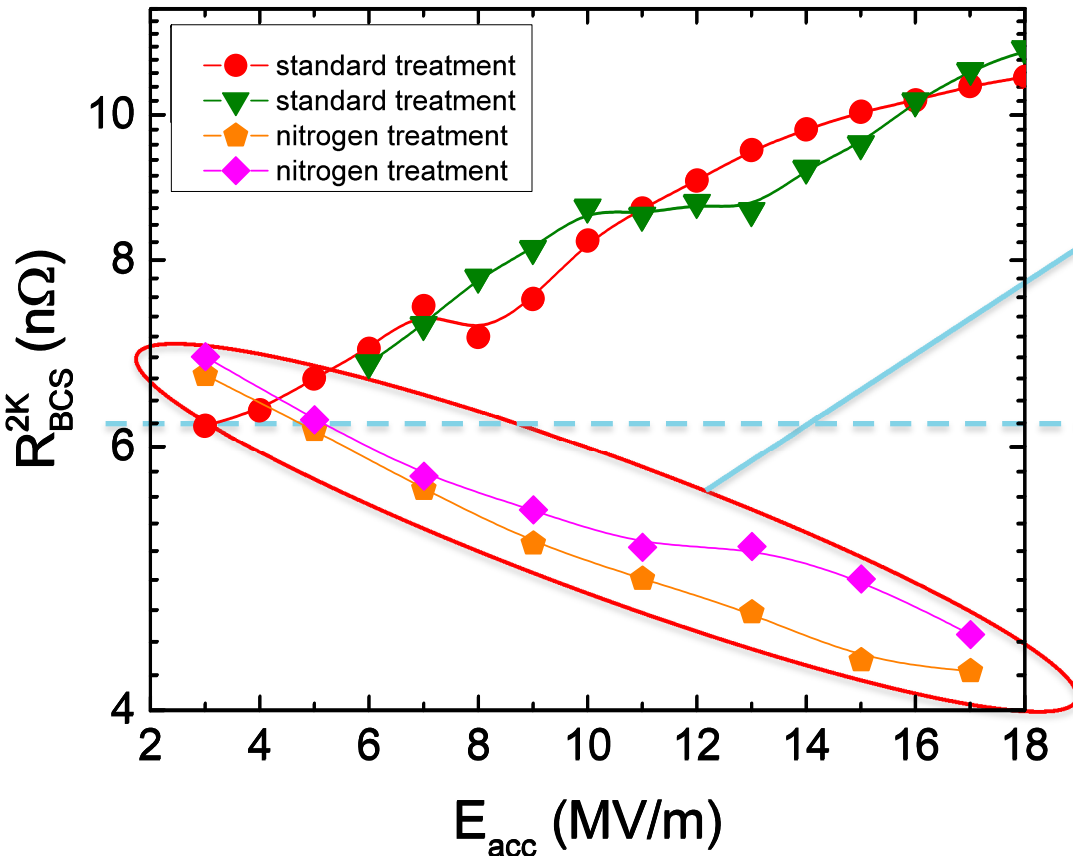


No visible Nb nitrides-teeth in near-surface show only Nb reflections

Confirms that root of improvement is from nitrogen as interstitial in the lattice

SIMS measurements show concentration of N one-two order of magnitude larger than background

Physics – perceived BCS limit has been overcome



Anti-Q-slope emerges from the BCS surface resistance decreasing with field

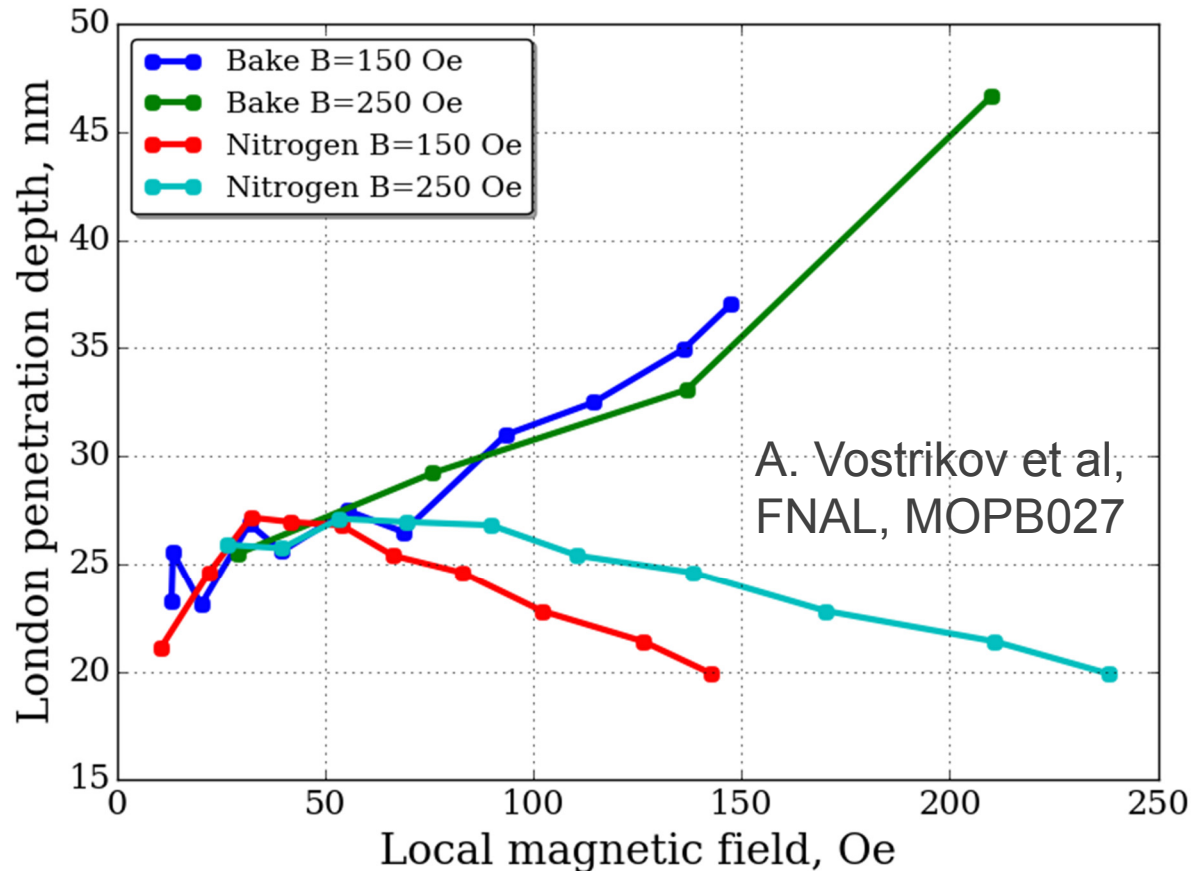
This was thought to be the lowest possible BCS resistance

N doping brings also lower than typical residual resistance <2 nanoOhms (non trapped flux related)

A. Grassellino et al, 2013 Supercond. Sci. Technol. **26** 102001 (Rapid Communication)

A. Romanenko and A. Grassellino, Appl. Phys. Lett. **102**, 252603 (2013)

Field dependence of the penetration depth – a possible explanation for the field dependence of BCS R_s ?

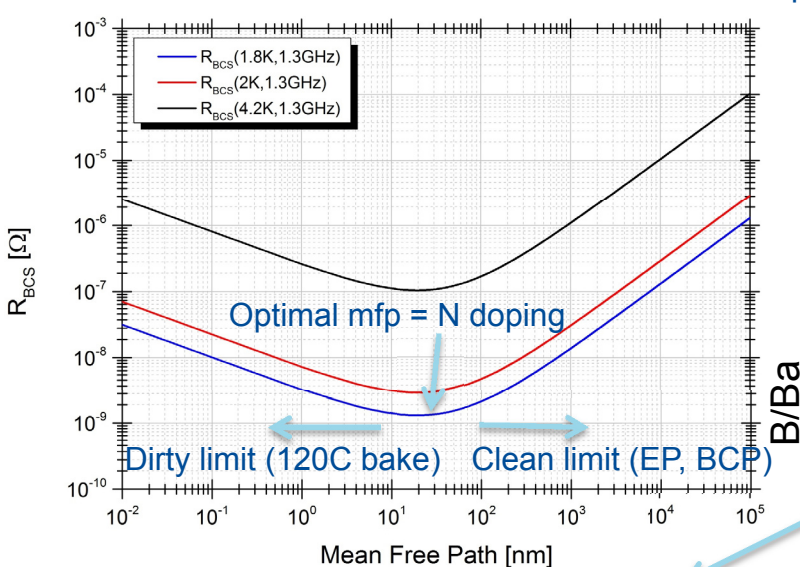


LEM μ SR measurements on 120C bake and doped cavity cutouts reveal that the penetration depth in the two cases have opposite field dependences, decreasing with field for N doping: possible origin of Q antislope?

How much nitrogen is needed for optimal performance?

The intermediate mean free path

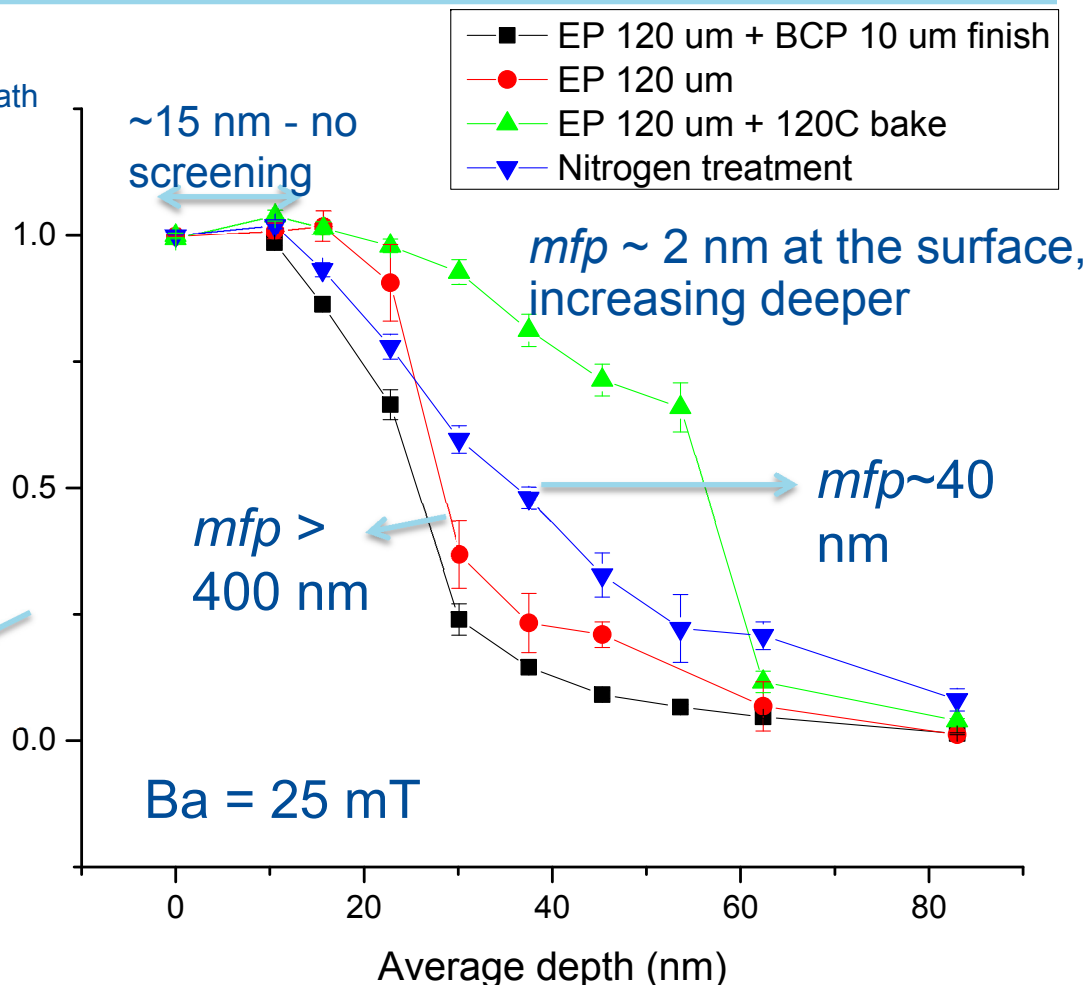
BCS surface resistance as a function of mean free path



BCP and EP unbaked -> strong screening, clean limit

EP+120C bake-> strongly suppressed m.f.p., gradient of the m.f.p. from the surface, dirty limit

N-doped -> intermediate m.f.p., at the predicted minimum for BCS (previously unexplored)

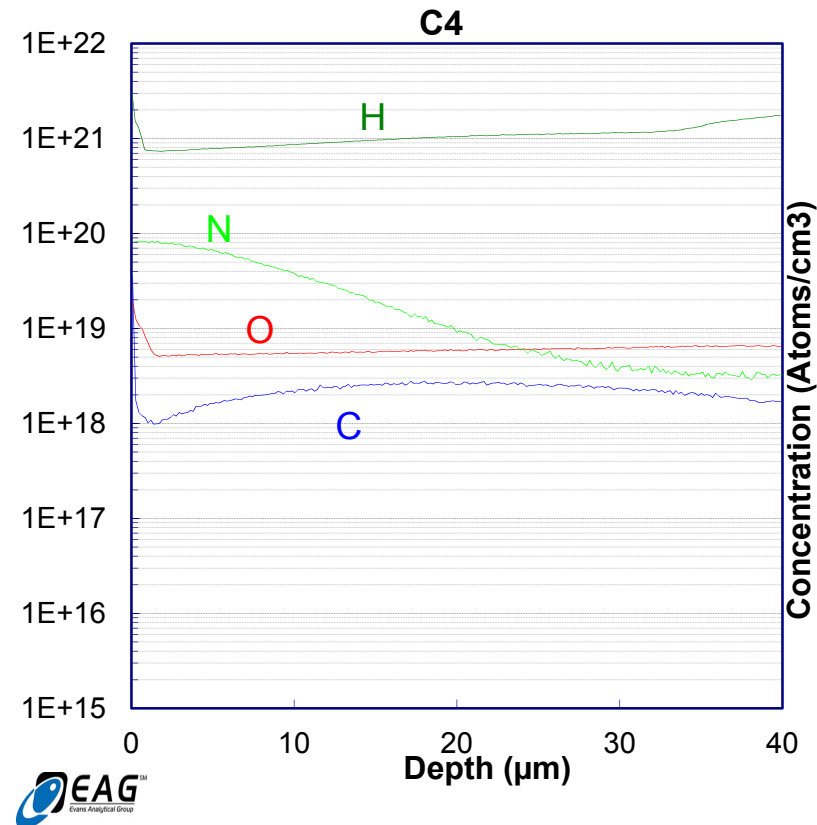


Meissner screening profiles for differently treated cutouts (Ba magnetic field applied parallel to sample surface = 25 mT). Allows to directly extract surface mfp

***Progress in N doping understanding:
what is the optimal N doping recipe?***

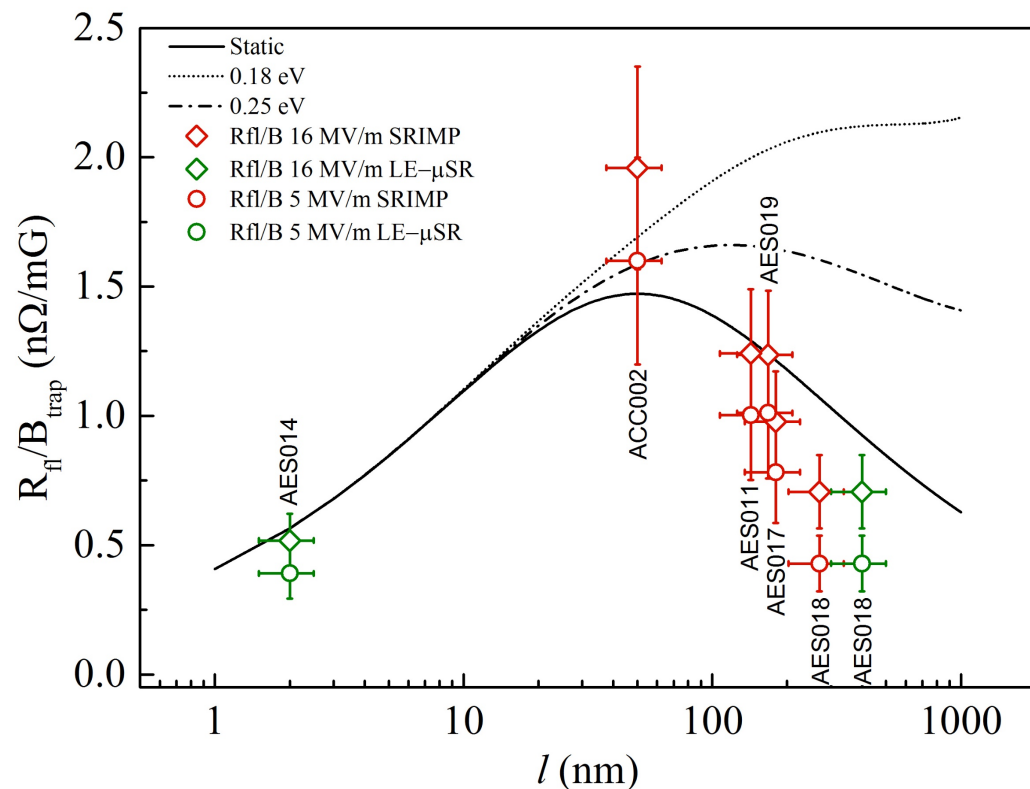
Parameters in play for recipe optimization: overdoped vs underdoped regime

- R_{BCS} (Bpk > 60 mT)
 - This is the most robust parameter; R_{BCS} is low for a very wide range of N concentration at the surface (> ~50 ppm)
 - Below (underdoped regime), R_{BCS} gradually returns to that of standard treatments
- R_0 (non trapped flux related)
 - If “overdoped” (> ~200 ppm) a strong field dependence of the surface resistance appears
 - If “underdoped”, residual continues to stay low for a wider range than R_{BCS}
- Sensitivity to trapped magnetic flux
 - Lower doping levels lead to smaller sensitivity to trapped flux
- Maximum quench field
 - Also improves with lighter doping level

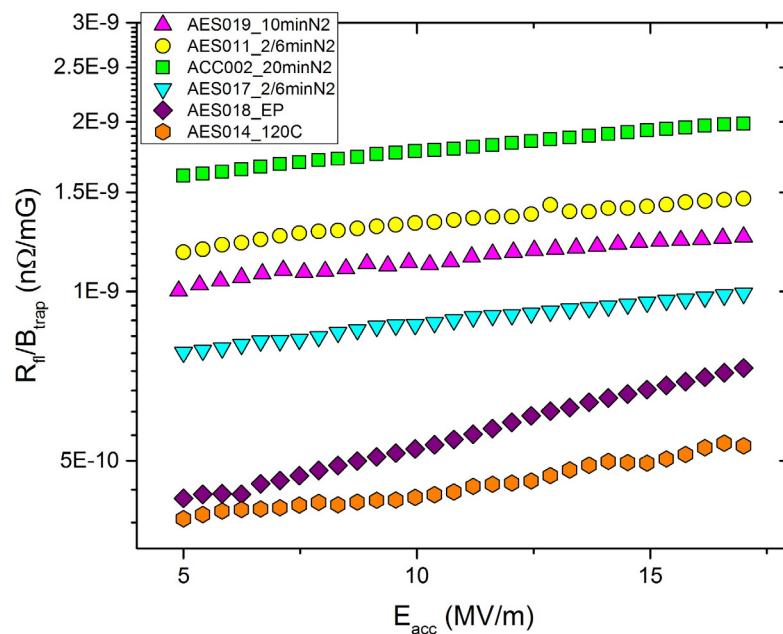


Is trapped magnetic flux sensitivity much higher for N doped cavities?

Depends on the doping level -and the accelerating field

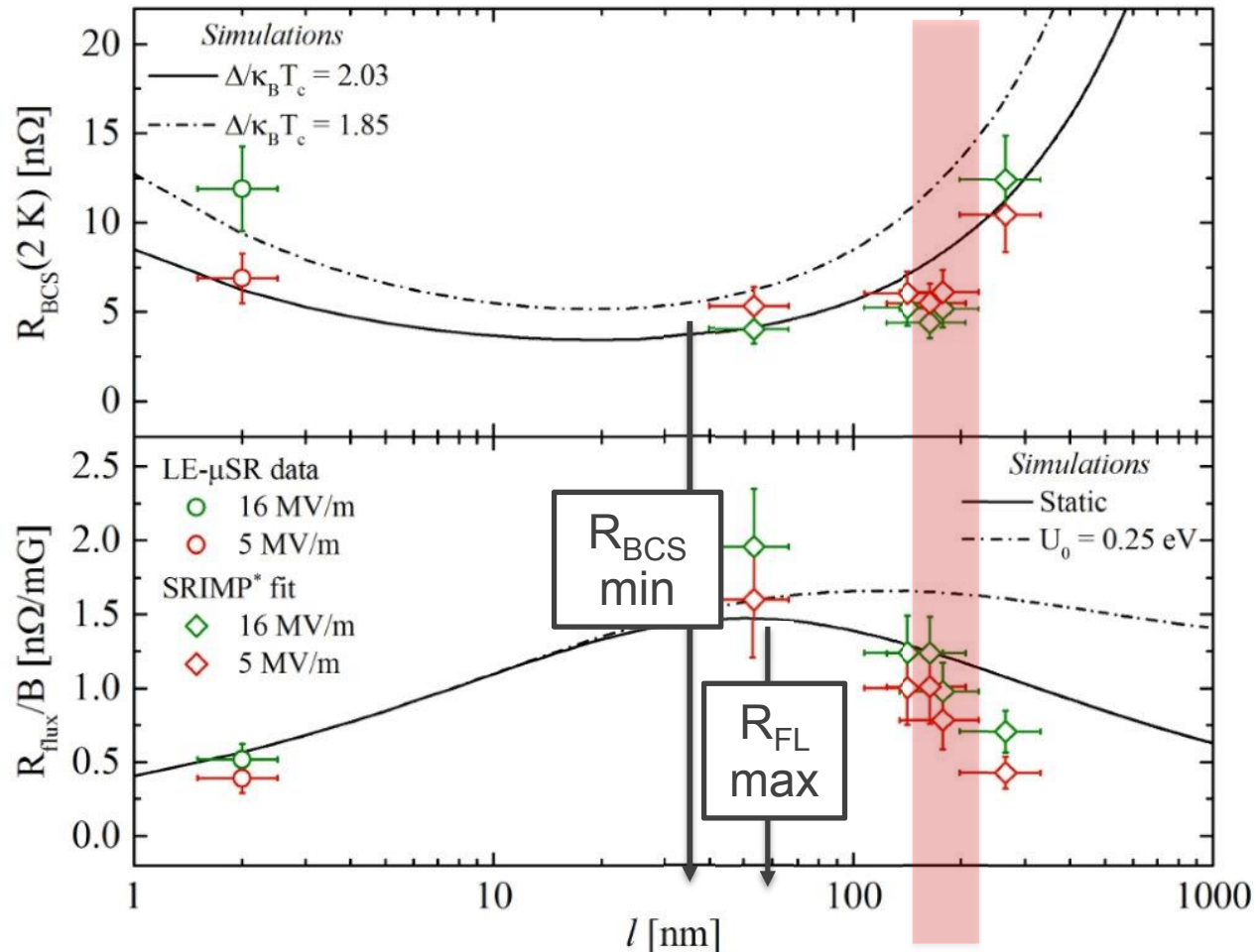


M. Martinello et al, MOPB015
M. Checchin et al, MOPB020



- Sensitivity to trapped flux for N doping improves with lighter doping (larger mfp)
- Not dramatically higher than standard (especially at higher accelerating fields):
 - 120C bake ~0.5 nOhm / mGauss
 - EP ~0.7
 - N dope (best) ~0.9

Recipe optimization: R_{BCS} vs flux sensitivity

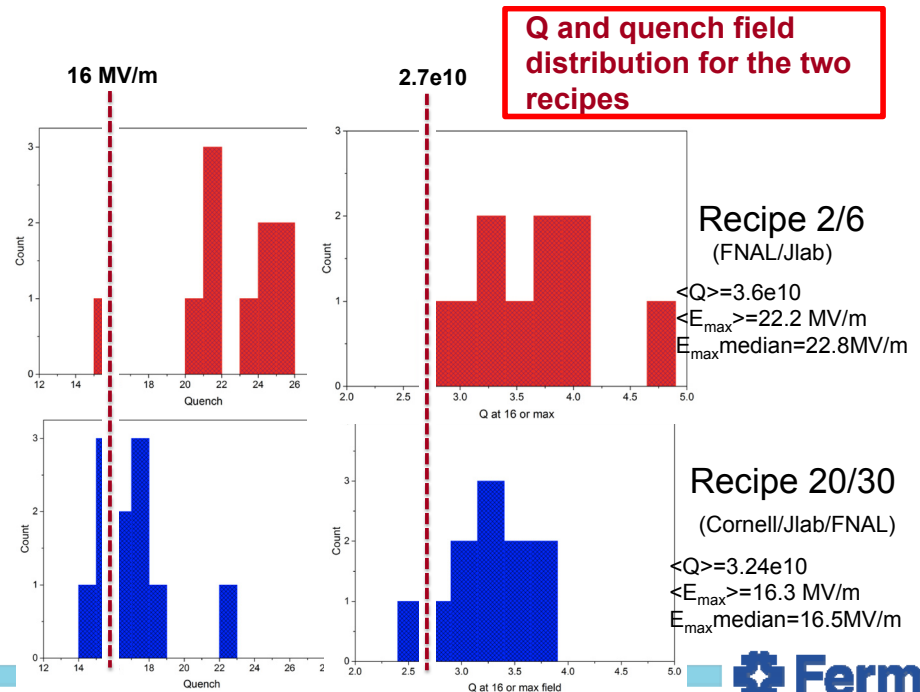
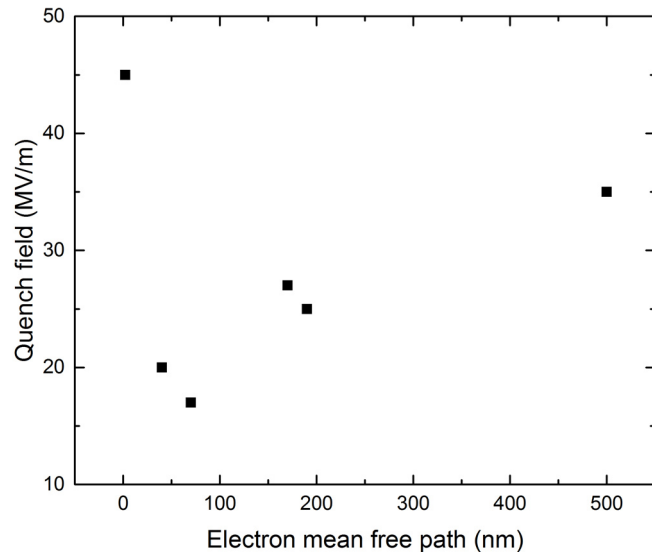


Larger mean free paths produce best performance...

But it is also interesting to notice the large windows of “unexplored”...

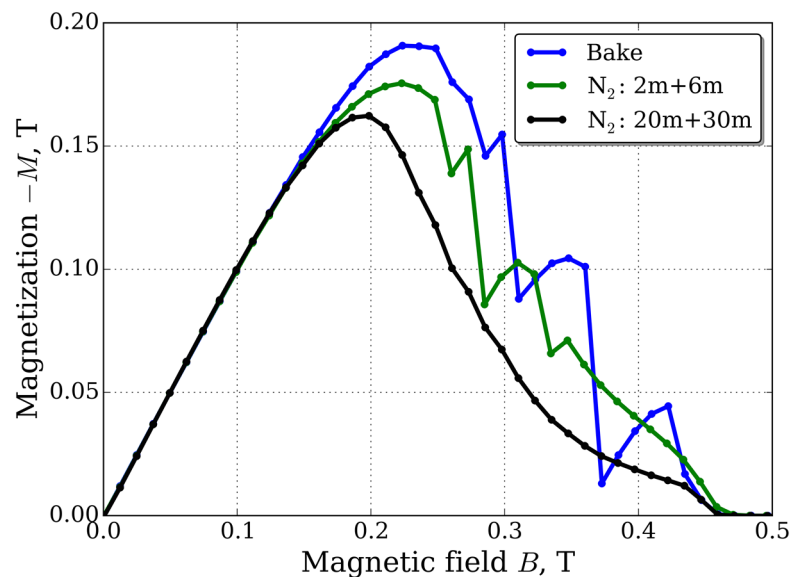
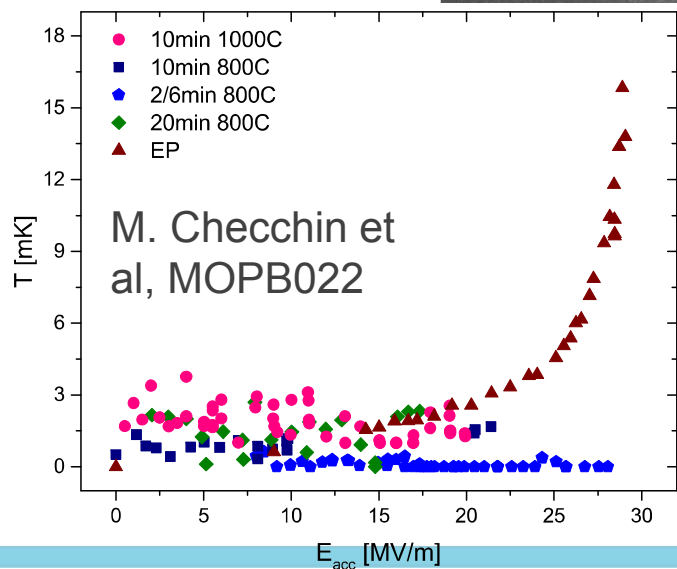
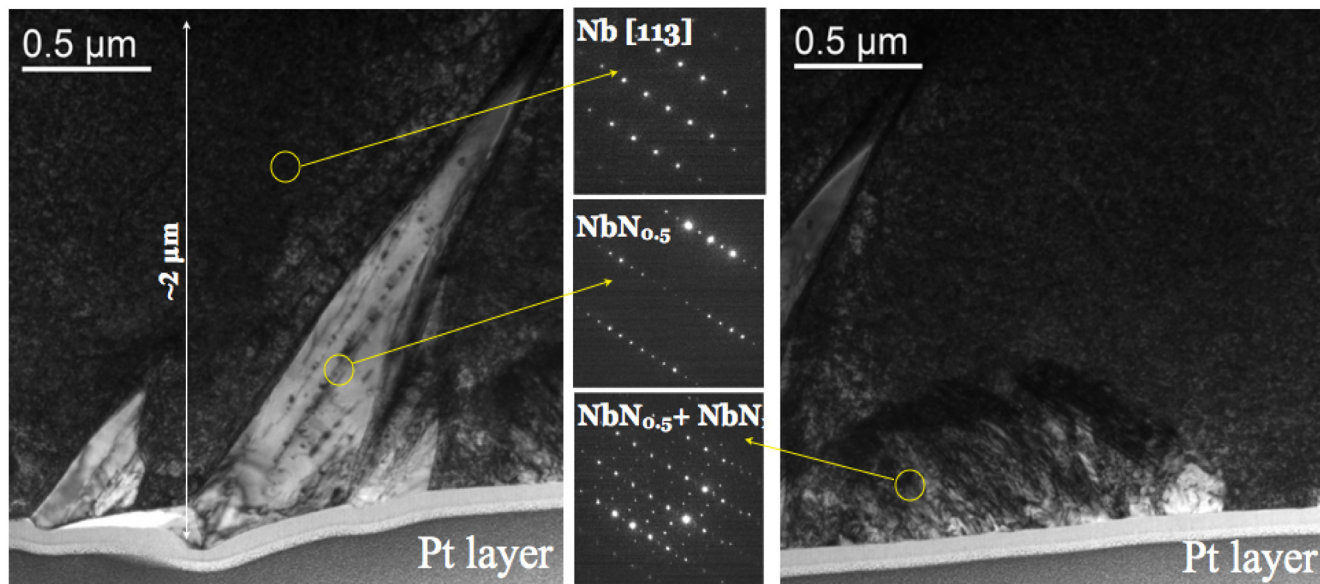
Recipe optimization: quench fields

- Light doping yields to higher quench field than heavy doping
- For same length of the doping step, quench field decreases with subsequent ‘anneal’ time (why?)
- For same recipe, quench fields are worse in nine cell than single cell cavities
- Quench fields are not sparse, they always ‘cluster’ around a value – different N doping levels produce different quench barriers
- More severe quench limitation $> \sim 200$ ppm concentration
- There is a trend – similar to the BCS minimum – for quench fields vs mean free path



New insights on quench in N doped cavities – magnetic peak field driven

Nitride
teeth...residual
nanonitrides post
EP?
Or premature flux
entry?



A. Vostrikov
et al,
MOPB027

Conclusions

- N doping has come a long way since last SRF
- Already demonstrated to systematically achieve unprecedented Q levels all the way to dressed cavities in cryomodule environment, technology ready for LCLS-2
- With their pros and cons, N doped cavities have been a new crucial tool for gaining new insights on surface resistance and its field dependence, trapped flux as a function of cooling and mean free path, and origin of quench
- What will the “yet unexplored” range of mean free paths bring?

